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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/086,689	03/04/2002	Takashi Hashimoto	H-1032	2817
7590 07/03/2003 Mattingly, Stanger & Malur, P.C. Suite 370 1800 Diagonal Road Alexandria, VA 22314			EXAM	iner ;
			VU, DAVID	
			ART UNIT	PAPER NUMBER
			2818	
			DATE MAILED: 07/03/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)				
	10/086,689	HASHIMOTO ET AL.				
. Office Action Summary	Examiner	Art Unit				
	DAVID VU	2818				
- The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a re - If NO period for reply is specified above, the maximum statutory perio - Failure to reply within the set or extended period for reply will, by statt - Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b). Status	. 1.136(a). In no event, however, ma bely within the statutory minimum of d will apply and will expire SIX (6) I the cause the application to become	y a reply be timely filed f thirty (30) days will be considered timely. MONTHS from the mailing date of this communication. e ABANDONED (35 U.S.C. § 133).				
1) Responsive to communication(s) filed on 04	1 March 2002 .					
24/6	This action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims						
4)⊠ Claim(s) 1-18 is/are pending in the applicati	on.					
4a) Of the above claim(s) is/are withdo	rawn from consideration.					
5) Claim(s) is/are allowed.						
6) Claim(s) is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) 1-18 are subject to restriction and/or election requirement.						
Application Papers						
9) The specification is objected to by the Examiner.						
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the	Examiner.					
Priority under 35 U.S.C. §§ 119 and 120		O C 440(a) (d) a= (D				
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ☐ All b) ☐ Some * c) ☐ None of:						
 Certified copies of the priority docume 						
2. Certified copies of the priority documents have been received in Application No						
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
14) Acknowledgment is made of a claim for dome	estic priority under 35 U.S	S.C. § 119(e) (to a provisional application).				
a) ☐ The translation of the foreign language [15] ☐ Acknowledgment is made of a claim for dome	provisional application has estic priority under 35 U.S	as been received. S.C. §§ 120 and/or 121.				
Attachment(s)						
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s	5) Notic	view Summary (PTO-413) Paper No(s) the of Informal Patent Application (PTO-152) r:				

DETAILED ACTION

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

Group I. Claims 11-14 drawn to device, classified in class 257, subclass 370.

Group II. Claims 1-10 and 15-18, drawn to process, classified in class 438, subclass 366.

The inventions are distinct, each from the other because of the following reasons: Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instance case unpatentabilities of the group I invention would not necessarily imply unpatentability of the group II invention, since the device of the group I invention could be made by the processes materially different from those of the group II invention, for example, etching and removing the silicon nitride film in isotropic fashion so that a side surface of the silicon nitride film is recessed from a side surface of the base electrode forming silicon film in the aperture by applying wet etching treatment on the silicon nitride film.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art because of their recognized divergent subject matter, restriction for examination purposes as indicated is proper.

Should Applicant Elect Group II

Group II of this application contains claims directed to the following patentably distinct species of the claimed invention:

Species 1, claims 1-10, method for manufacturing a semiconductor device comprising the steps of: etching and removing the silicon nitride film in isotropic fashion so that a side surface of the silicon nitride film is recessed from a side surface of the base electrode forming silicon film in the aperture by applying wet etching treatment on the silicon nitride film.

Species 2, claim 15, method for manufacturing a semiconductor device comprising the steps of: etching the patterned second insulation film located under the emitter electrode so that a side surface of the second insulation film is recessed from a side surface of the emitter electrode.

Species 3, claim 16, method for manufacturing a semiconductor device comprising the steps of: recessing the second insulation film so that an aperture width of the second insulation film is larger than an aperture width of the base electrode forming conductive film in the aperture.

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Species 4, claim 17, method for manufacturing a semiconductor device comprising a step of applying oxidation treatment to form an insulation film that functions as a protection film during epitaxial growing on the emitter aperture prior to selective growing of a base region forming epitaxial layer on a semiconductor substrate.

Species 5, claim 18, method for manufacturing a semiconductor device comprising a step of: forming a silicide layer by depositing a metal film on the semiconductor substrate and applying thermal treatment after a side surface of an insulation film interposed between an emitter electrode and a base electrode of a bipolar transistor.

Should applicant elect Group II, applicant is required under 35 U.S.C. 121 to elect a single disclosed species for prosecution on the merits to which the claims shall be restricted if no generic claim is finally held to be allowable. Currently, no claims are generic.

Applicant is advised that a reply to this requirement must include an identification of the species that is elected consonant with this requirement, and a listing of all claims readable thereon, including any claims subsequently added. An argument that a claim is allowable or that all claims are generic is considered nonresponsive unless accompanied by an election.

Upon the allowance of a generic claim, applicant will be entitled to consideration of claims to additional species which are written in dependent form or otherwise include all the limitations of an allowed generic claim as provided by 37 CFR 1.141. If claims are added after the election, applicant must indicate which are readable upon the elected species. MPEP § 809.02(a).

Should applicant traverse on the ground that the species are not patentably distinct, applicant should submit evidence or identify such evidence now of record showing the species to be obvious variants or clearly admit on the record that this is the case. In either instance, if the examiner finds one of the inventions unpatentable over the prior art, the evidence or admission may be used in a rejection under 35 U.S.C. 103(a) of the other invention.

Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a diligently filed petition under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(h).

Any inquiry concerning this communication on earlier communications from the examiner should be directed to David Vu whose telephone number is (703) 305-0391. The examiner can normally be reached on Monday-Friday from 7:30 AM to 5:00 PM. The examiner's supervisor, David Nelms can be reached on (703) 308-4910. The fax phone number for the organization where this application or proceeding is assigned is (703) 308-7724.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 3080956

DV

David Vu

HOAI HO PRIMARY EXAMINER